L Number	Hits	Search Text	DB	Time stamp
1	132	· · · · · · · · · · · · · · · · · · ·	USPAT;	2004/10/25 17:17
-		@pd>=20040714	US-PGPUB;	2001, 20, 20 2, 11,
			EPO; JPO;	
			DERWENT;	
	İ		IBM TDB	
2	41	(700/99-103,121;702/177,184.ccls. and	USPAT;	2004/10/25 17:30
-		@pd>=20040714) and maintenance	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
3	25	(700/99-103,121;702/177,184.ccls. and	USPAT;	2004/10/25 17:35
		@pd>=20040714) and maintenance and schedul\$6	US-PGPUB;	
1			EPO; JPO;	
			DERWENT;	
			IBM TDB	
4	38	maintenance same schedul\$6 same gap	USPAT;	2004/10/25 18:08
			US-PGPUB;	
		·	EPO; JPO;	
			DERWENT;	
			IBM TDB	
5	149	(maintenance near schedul\$6) with (downtime	USPAT;	2004/10/25 18:09
	1	or down-time or "down time" or gap)	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
6	2	(maintenance near schedul\$6) with (gap)	USPAT;	2004/10/25 18:11
			US-PGPUB;	' '
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	j l
7	17	(maintenance near schedul\$6) with (space or	USPAT;	2004/10/25 18:11
		spacing)	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	204	702/184.ccls.	USPAT;	2004/07/13 12:59
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	100	702/177.ccls.	USPAT;	2004/07/13 13:09
	1		US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	320	700/1001-	IBM_TDB	
_ <del>-</del>	320	700/100.ccls.	USPAT;	2004/07/13 13:09
			US-PGPUB;	
			EPO; JPO;	
		· ·	DERWENT;	
_	90	700/100.ccls. and maintenance	IBM_TDB	2004/07/13 13:19
		, , , , , , , , , , , , , , , , , , ,	USPAT; US-PGPUB;	2004/0//13 13:19
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
<u>-</u>	12	maintenance with schedul\$5 with gap	USPAT;	2004/07/13 13:23
	12	warness with boneautys with gap	US-PGPUB;	2004/07/13 13:23
	1		EPO; JPO;	
			DERWENT;	
•			IBM TDB	
_	564	maintenance near2 gap	USPAT;	2004/07/13 13:24
			US-PGPUB;	,, 13 13.24
			EPO; JPO;	
·			DERWENT;	
			IBM TDB	
-	282	maintenance near gap	USPAT;	2004/07/13 13:24
		2 3~F	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
	•	Language and the second		L

-	0	(maintenance near gap) same schedul\$5	USPAT;	2004/07/13 13:24
			US-PGPUB;	
			EPO; JPO;	<u> </u>
			DERWENT;	
			IBM_TDB	i
-	1	(maintenance near2 gap) same schedul\$5	USPAT;	2004/07/13 13:24
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
}			IBM_TDB	<b>!</b>
-	289	· · · · · · · · · · · · · · · · · · ·	USPAT;	2004/07/13 15:29
		downtime or "down time" or "down-time")	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	1.0	maintanana with askadulas with (	IBM_TDB	0004/05/00 05 00
-	12	maintenance with schedul\$5 with (parallel)	USPAT;	2004/07/13 15:32
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
_	24	maintenance with achedules with	IBM_TDB	2004/07/12 16 00
-	44	maintenance with schedul\$5 with (simultaneous\$6)	USPAT;	2004/07/13 16:00
		(PIMATCAMEONS \$ 0 )	US-PGPUB; EPO; JPO;	
			DERWENT; IBM TDB	
	67	(maintenance near (simultaneous\$6 or	-	2004/07/13 16:08
	"	parallel)) and (downstream or upstream)	USPAT; US-PGPUB;	2004/07/13 16:08
		pararier, and (downstream or upstream)	EPO; JPO;	
			DERWENT;	
			IBM TDB	
-	50	maintenance near (downstream or upstream)	USPAT;	2004/07/13 16:09
		marineenance near (downstream of apscream)	US-PGPUB;	2004/07/13 16:09
			EPO; JPO;	ļ
			DERWENT;	
			IBM TDB	
-	131	maintenance with (downstream or upstream)	USPAT;	2004/07/13 16:12
		with (schedul\$5 or perform\$5)	US-PGPUB;	
1		• • • • • • • • • • • • • • • • • • • •	EPO; JPO;	
	İ		DERWENT;	
			IBM TDB	
-	15175	maintenance near (schedul\$5 or perform\$5)	USPAT;	2004/07/13 16:47
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	4		USPAT;	2004/07/13 16:21
		with line with (upstream or downstream)	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	·
1_		/maintananga naga /aabada145 5 4=33	IBM_TDB	0001/05/55 55 5
-	75	(	USPAT;	2004/07/13 16:23
		same ("manufacturing line" or "production	US-PGPUB;	
		line" or "assembly line")	EPO; JPO;	
			DERWENT;	
_	32	(maintenance near (schodults or routewest)	IBM_TDB	2004/07/12 15 65
	32	<pre>(maintenance near (schedul\$5 or perform\$5)) with downstream</pre>	USPAT;	2004/07/13 17:03
		with downstream	US-PGPUB;	
			EPO; JPO;	
			DERWENT; IBM TDB	
_	401	maintenance near timing	USPAT;	2004/07/13 20:55
			US-PGPUB;	2004/07/13 20:55
			EPO; JPO;	
			DERWENT;	
			IBM TDB	
_	10	(maintenance near timing) and	USPAT;	2004/07/13 20:58
		("manufacturing line" or "production line"	US-PGPUB;	
		or "assembly line")	EPO; JPO;	
		· ·	DERWENT;	
			IBM TDB	

			,	
_	2	(maintenance near wait\$5) and	USPAT;	2004/07/13 20:59
		("manufacturing line" or "production line"	US-PGPUB;	1
		or "assembly line")	EPO; JPO;	1
			DERWENT;	
			IBM_TDB	
-	215	700/121.ccls. and maintenance	USPAT;	2004/07/13 20:59
			US-PGPUB;	
			EPO; JPO;	1
			DERWENT;	
			IBM_TDB	
-	38	, , , , , , , , , , , , , , , , , , , ,	USPAT;	2004/07/13 21:14
		schedul\$9)	US-PGPUB;	10
i			EPO; JPO;	1
			DERWENT;	
	1		IBM_TDB	
-	13	maintenance with schedul\$9 with idl\$6	USPAT;	2004/07/13 21:17
			US-PGPUB;	]
			EPO; JPO;	
			DERWENT;	
			IBM TDB	į
-	470	700/99,101-103.ccls.	USPĀT;	2004/07/13 21:18
			US-PGPUB;	
1			EPO; JPO;	
			DERWENT;	
	1.		IBM TDB	
-	38	700/99,101-103.ccls. and (schedul\$5 with	USPAT;	2004/07/13 21:26
1		maintenance)	US-PGPUB;	
1			EPO; JPO;	
			DERWENT;	
	i		IBM TDB	
_	30	maintenance with schedul\$9 with during with	USPAT;	2004/07/13 21:42
		(downtime or "down time" or "down-time")	US-PGPUB;	2001, 07, 15 21.12
		,	EPO; JPO;	
			DERWENT;	l
			IBM TDB	į
-	691	ASML-NETHERLANDS-BV ASML-NETHERLANDS-B-V	USPAT;	2004/07/13 21:47
		"ASML-NETHERLANDS-B.V" ASML-NETHERLANDS-NV	US-PGPUB;	2001/07/15 21.47
		ASML-MASKTOOLS-NETHERLANDS-BV	EPO; JPO;	
		ASML-MASKTOOLS-NETHERLANDS-B-V	DERWENT;	
		"ASML-MASKTOOLS-NETHERLANDS-B.V"	IBM TDB	
		ASML-MASKTOOLS-B-V "ASML-MASKTOOLS-B.V"	12122	
		ASML-NETHERLANDS		
-	28		USPAT;	2004/07/13 21:53
		"ASML-NETHERLANDS-B.V" ASML-NETHERLANDS-NV	US-PGPUB;	2004/07/13 21:33
		ASML-MASKTOOLS-NETHERLANDS-BV	EPO; JPO;	
		ASML-MASKTOOLS-NETHERLANDS-B-V	DERWENT;	
		"ASML-MASKTOOLS-NETHERLANDS-B.V"	IBM_TDB	
1		ASML-MASKTOOLS-B-V "ASML-MASKTOOLS-B.V"	12.1108	
		ASML-NETHERLANDS) and maintenance		
_	16		USPAT;	2004/07/13 21:55
	"	schedul\$6	US-PGPUB;	2004/0//13 21:35
	1		EPO; JPO;	
			DERWENT;	
ĺ			1	į l
_	726	(semiconductor or wafer) and ((coater or	IBM_TDB   USPAT;	2004/07/12 21:53
	/20	developer or track) same maintenance)	USPAT; US-PGPUB;	2004/07/13 21:57
		developer or crack, balle maintenance,		
			EPO; JPO; DERWENT;	
			1	
_	35	(semiconductor or wafer) and ((coater or	IBM_TDB USPAT;	2004/07/13 22 25
	35	developer or track) same maintenance same	1	2004/07/13 22:05
	j	schedul\$5)	US-PGPUB;	
		Benegary3/	EPO; JPO;	
			DERWENT;	
_	556	coater with developer	IBM_TDB	2004/05/12 55 5=
	556	coater with developer	USPAT;	2004/07/13 22:05
	; I		US-PGPUB;	
	<u> </u>		EPO; JPO;	1
			DERWENT;	
,	L		IBM_TDB	

	7		· · · · · · · · · · · · · · · · · · ·	<del>, , _ , _ , _ ,</del>
-	5	coater with developer with maintenance	USPAT; US-PGPUB;	2004/07/13 22:09
			EPO; JPO;	
			DERWENT; IBM TDB	
-	3	(+	USPAT;	2004/07/13 22:10
		same (expos\$5)	US-PGPUB; EPO; JPO;	
			DERWENT;	
	5	coater same developer same maintenance same	IBM_TDB USPAT;	2004/07/13 22:11
		(stepper or expos\$5 or photolithography)	US-PGPUB;	2004/07/13 22:11
			EPO; JPO;	
			DERWENT; IBM TDB	
-	324		USPAT;	2004/07/14 12:24
		or lithography or photolithography) and maintenance	US-PGPUB; EPO; JPO;	
			DERWENT;	
_	3	(coater and developer and (stepper or	IBM_TDB USPAT;	2004/07/14 12:06
		expos\$5 or lithography or photolithography)	US-PGPUB;	2004/07/14 12:00
		and maintenance) and bottleneck	EPO; JPO; DERWENT;	
			IBM TDB	
-	39	,	USPAT;	2004/07/14 12:07
		expos\$5 or lithography or photolithography) and maintenance) and schedul\$5	US-PGPUB; EPO; JPO;	
			DERWENT;	
_	5460	(coater or developer or track) with	IBM_TDB   USPAT;	2004/07/14 12:34
		maintenance	US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM_TDB	
-	16	((coater or developer or track) with maintenance with schedul\$5) and	USPAT; US-PGPUB;	2004/07/14 12:26
		(semiconductor or wafer or lithography or	EPO; JPO;	
		photolithography)	DERWENT; IBM TDB	
_	1323	(coater or developer) with maintenance	USPĀT;	2004/07/14 12:36
			US-PGPUB;	
			EPO; JPO;   DERWENT;	
	161		IBM_TDB	
-	161	((coater or developer) with maintenance) and (semiconductor or wafer or photolithography	USPAT; US-PGPUB;	2004/07/14 13:07
		or lithography)	EPO; JPO;	
			DERWENT; IBM TDB	
-	31	((coater or developer) same maintenance same	USPAT;	2004/07/14 13:19
		<pre>(schedul\$5 or perform\$5) same (expos\$5 or stepper or photolithography or lithography))</pre>	US-PGPUB; EPO; JPO;	
		Transfer Francisco Company	DERWENT;	
_	189	(coater or developer or track) with	IBM_TDB USPAT;	2004/07/14 16:43
		maintenance with schedul\$5	US-PGPUB;	2007/0//14 10:43
			EPO; JPO;	
			DERWENT; IBM_TDB	
-	140	(expos\$5 with longer with (coat\$5 or	USPAT;	2004/07/14 16:45
		develop\$)) and maintenance	US-PGPUB; EPO; JPO;	
			DERWENT;	
-	132	700/99-103,121;702/177,184.ccls. and	IBM_TDB USPAT;	2004/10/25 17:17
		@pd>=20040714	US-PGPUB;	,, <b>-</b> ,,,,,,,,,,
			EPO; JPO; DERWENT;	
			IBM_TDB	